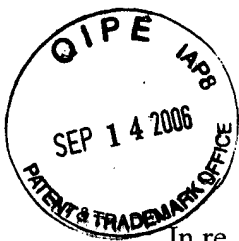


IFW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Michael DiBattista et al.

Serial No.: 10/848,925

Filed: May 19, 2004

For: Physical Nano-Machining With
a Scanning Probe System for
Integrated Circuit Modification

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Art Unit: 2815

Examiner: Matthew C. Landau

Atty Docket: ITL.1127US
P19033

Assignee: Intel Corporation

Mail Stop **Amendment**
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

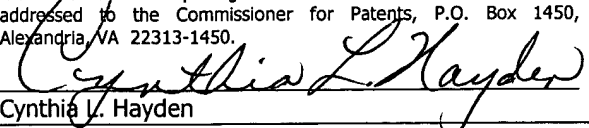
RESPONSE TO RESTRICTION REQUIREMENT

Sir:

In response to the restriction requirement mailed August 31, 2006, please amend the
above-referenced patent application as follows:

Date of Deposit: September 12, 2006

I hereby certify under 37 CFR 1.8(a) that this correspondence is
being deposited with the United States Postal Service as **first class**
mail with sufficient postage on the date indicated above and is
addressed to the Commissioner for Patents, P.O. Box 1450,
Alexandria, VA 22313-1450.


Cynthia L. Hayden